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Pinned-surface and double-junction photodiode type super high-performance image sensor with built-in solar cell structure

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Highlights:

- Semiconductor band theory of silicon-based double and triple Junction type photodiodes.
- Electron/hole pair separation enhanced by surface conduction band bending in surface P+P hole accumulation region.
- Energy spectrum density and penetration depth of Sun light into silicon crystal.
- Maximum Power Tracking Technology (MPTT) on pinned-surface double-junction photodiode type solar cell.
- Floating-surface hole/electron recombination loss of the conventional single junction type solar cell.